

U.S. UTILITY Patent Application

APPL NUM 10054095	FILING DATE 01/22/2002	CLASS 430	SUBCLASS 1	GAU 1752	EXAMINER JUN 11 2002
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**CONTINUING DATA VERIFIED:					
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** FOREIGN APPLICATIONS VERIFIED: REPUBLIC OF KOREA 2001-38030 06/29/2001					
PG-PUB	DO NOT PUBLISH <input type="checkbox"/>	RESCIND <input type="checkbox"/>			
Foreign priority claimed <input type="checkbox"/> yes <input type="checkbox"/> no 35 USC 119 conditions met <input type="checkbox"/> yes <input type="checkbox"/> no Verified and Acknowledged Examiners's initials				ATTORNEY DCKET NO 30205/37777	
TITLE : Chemical amplification photoresist monomers, polymers therefrom and photoresist compositions containing the same					
<small>U.S. DEPT. OF COM. / PAT. & TM. PTO-475L (Rev. 12-54)</small>					

NOTICE OF ALLOWANCE MAILED			CLAIMS ALLOWED		
			Total Claims		Print Claim for O.G.
ISSUE FEE			DRAWING		
Amount Due	Date Paid		Sheets Drawn	Figs. Drawn	Print Figs.
<input type="checkbox"/> TERMINAL DISCLAIMER		Primary Examiner	Application Examiner		
		PREPARED FOR ISSUE			
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